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ST developments in SiC manufacturing to address the EV revolution

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Agenda

1 EV market development

2 SiC demand in electric vehicle subsystems

3 Continuous development of the technology node

4 SiC manufacturing challenges

5 Introduction of new manufacturing technologies

6 Vertical integration of the manufacturing cycle

7 Capacity expansion to support growth

8 Key takeaways

Semiconductors addressing carbon neutrality

Silicon and wide-bandgap (silicon carbide & gallium nitride) power transistors

Tens of millions of cars



Millions of chargers



Hundreds of thousands of stations



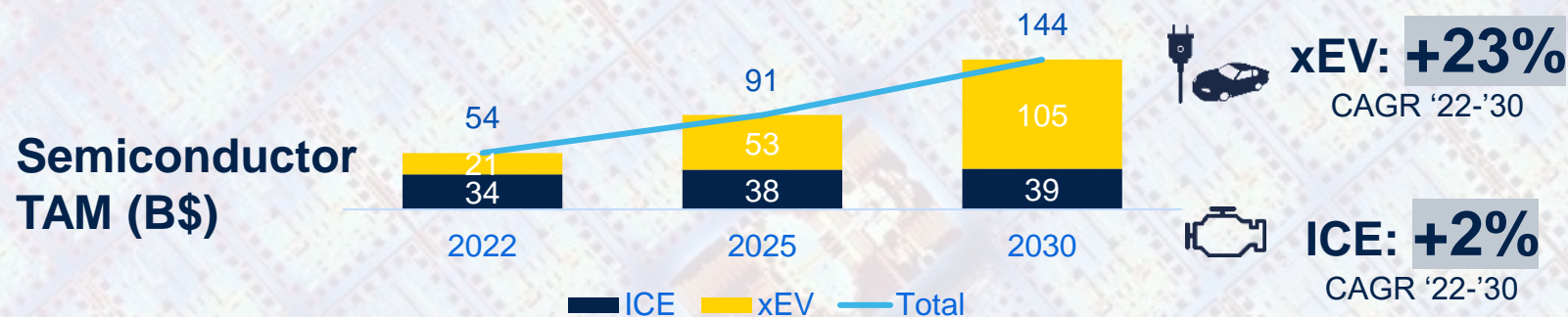
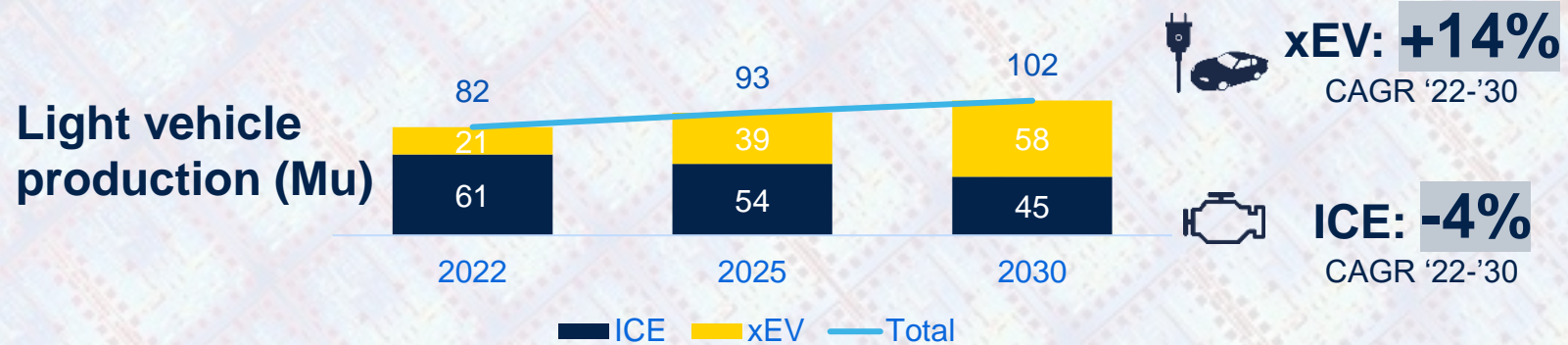
Millions of solar inverters



- Electrification of energy consumption
- Transportation decarbonization
- Renewable energy generation

- Powertrain electrification
- Smart vehicle / connectivity
- ADAS / autonomous drive
- Software / Hardware decoupling

Chip demand rising faster than vehicle production



ICE = internal combustion engine
xEV = battery electric vehicle, fuel cell electric vehicle, full hybrid, plug-in hybrid, mild hybrid.

Electric powertrain efficiency and integration

From range to efficiency

Focus on holistic efficiency improvement in e-powertrain by reducing electric and mechanical losses and improving thermal management.

Integration

Integrated e-axle (e-motor, inverter, gearbox) and integrated power units (DC-DC, OBC, PDU) for fully integrated high voltage systems and extended battery packs

Modular approach

Modular and scalable powertrain systems (battery, e-motor, inverter) converging vehicle platforms and focusing on enabling technology platforms

OBC = on board charger
PDU = power distribution unit

How car electrification impacts power semiconductors



Traction inverter

100-250kW

1.5x

SiC MOSFET

Si IGBT

24-48 transistors

OBC / DC-DC

11k-44kW

1x

SiC MOSFET

Si HV MOSFET

GaN HEMTs

6-14 transistors



Charging station DC-DC

100k-250kW

0.15x

SiC MOSFET

12-18 transistors



Energy storage

>1MW

0.015x

SiC MOSFET

>100 transistors

New automotive applications powered by SiC

Fuel cell applications

- Interleaved power DC-DC
- High speed pump

Battery disconnect

- Replace mechanical relay / solid state contactors

DC link discharge

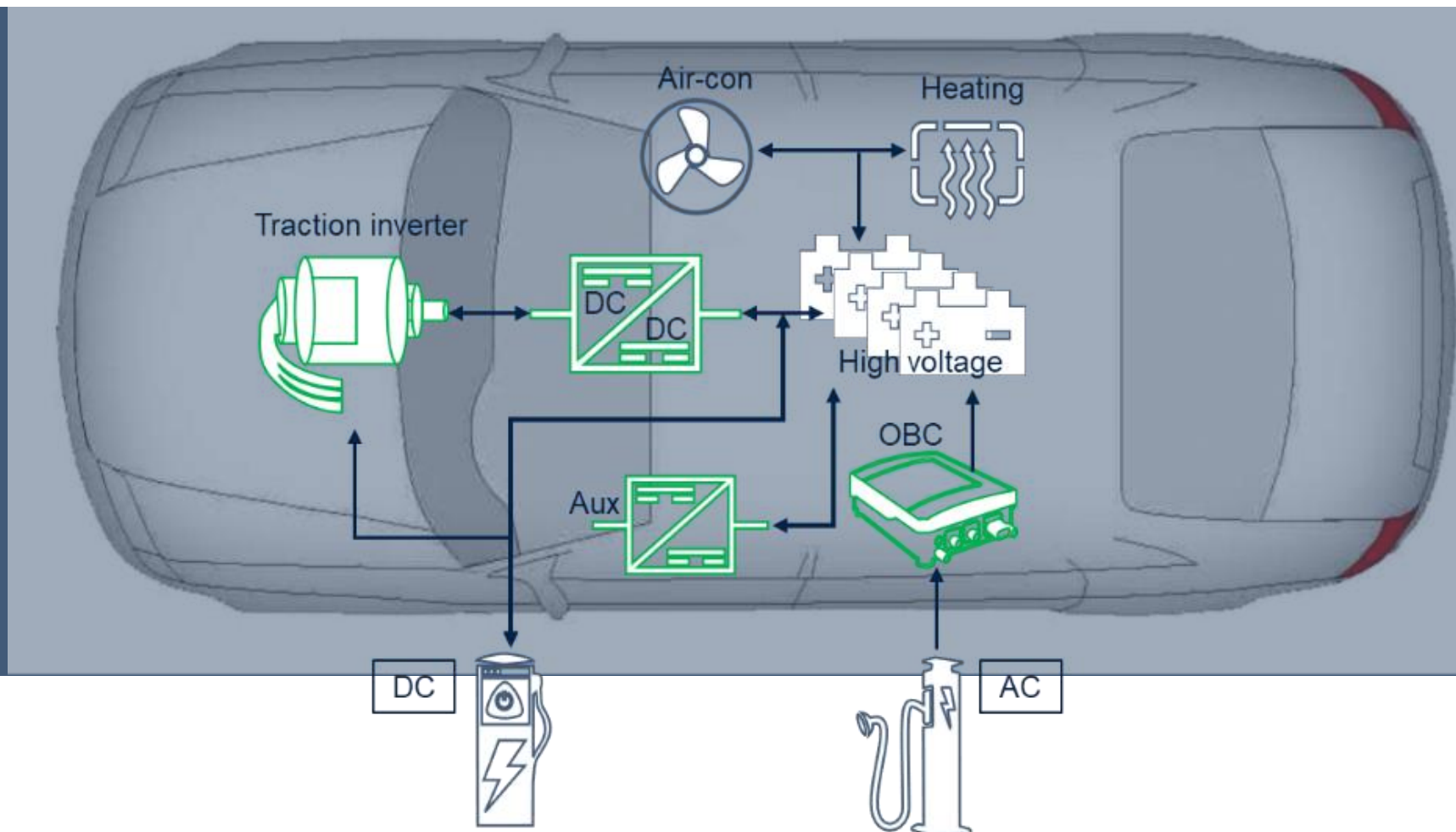
- Discharging HV for safety

Smart power distribution

- Protection of auxiliaries
- Boardnet optimization

Various

- Heating control
- High speed pump (turbo)
- E-Compressor



SiC MOSFET technology development

Technology Roadmap

■ Planar ■ Not Planar

Gen1

Optimized **Ron** and **Tj** for **motor drive** applications

Gen2

Balanced **Ron** and **Qg** for industrial and automotive

Gen3

Lower Ron vs. **Gen2** maximizes the driving range of EVs

Gen4

Reduced Ron vs. **Gen3** tailored for traction inverter

Gen5

Innovative **high power density technology** structure

R&D

Radical innovation, outstanding **Ron** value at hot temperature and further **Ron** reduction vs. **Gen5**

The major differences between Si and SiC

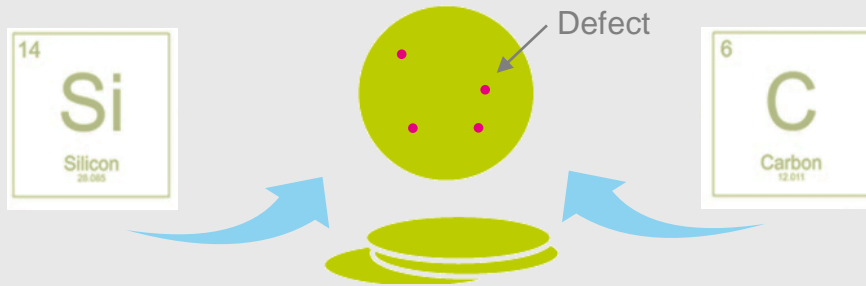


	Si	SiC
State-of-the-art Wafer size	8-12"	6"
Ingot length	1-2 meters	0.04 meters
Time to growth	1 day	2 weeks
Wafers per ingot	~2000	~50-100

SiC fabrication enlarges its scope to 8" dimensions.

Manufacturing challenges of silicon carbide

Higher intrinsic material defectiveness leads to more complex manufacturing for quality & reliability targets

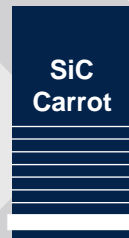


SiC ingot manufacturing



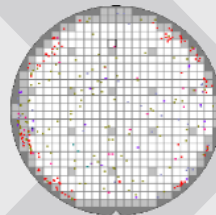
Seed defectiveness propagation

Sawing process



Physical defect mapping at wafer level

SiC wafer testing



Harder material requires a more sophisticated manufacturing process at key diffusion steps



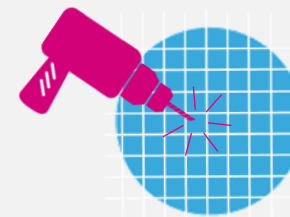
$>1700^{\circ}\text{C}$

Annealing
(Vs. 800°Si)



500°C

Ion Implantation
(Vs. 25°Si)



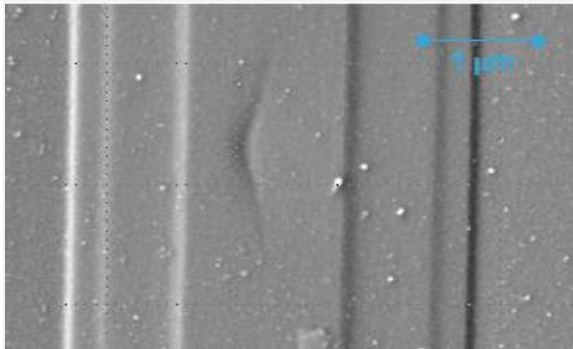
Harder etching phase
(similar to diamond)



More accurate photolithography to define dopant shape

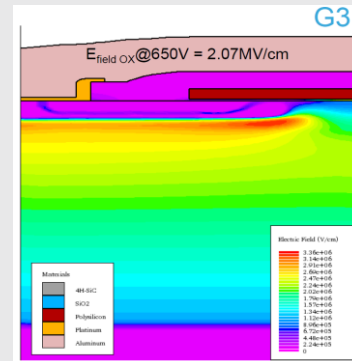
Wide-bandgap deployment and validation

Failure analysis



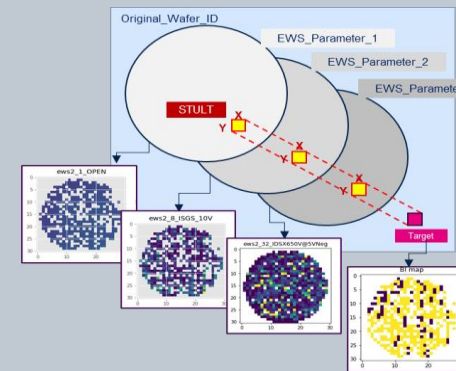
- Identification of new failure modes
- Effectiveness evaluation of screening methods
- Support for customer use in application
- New FA techniques

Design improvement



- Design fine tunings based on new failure mode
- Design for reliability and more margin
- Front-end & back-end new material and design solution evaluation

Testing improvement



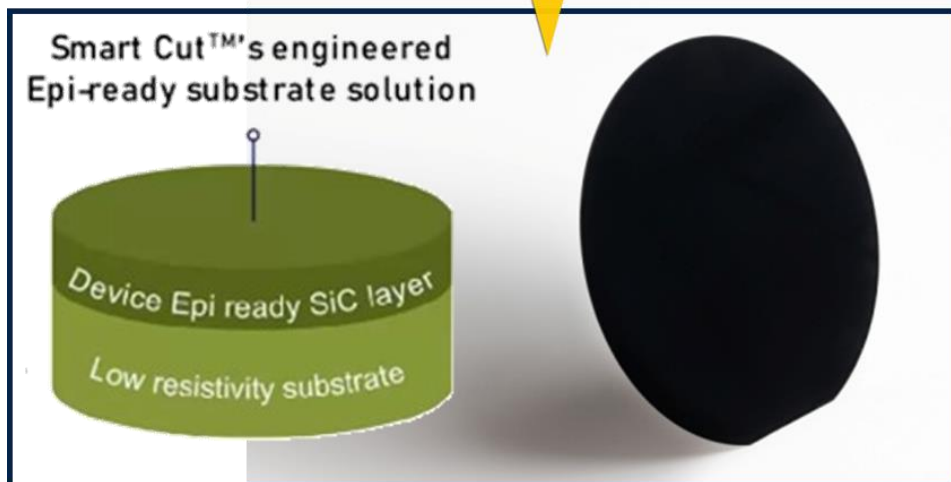
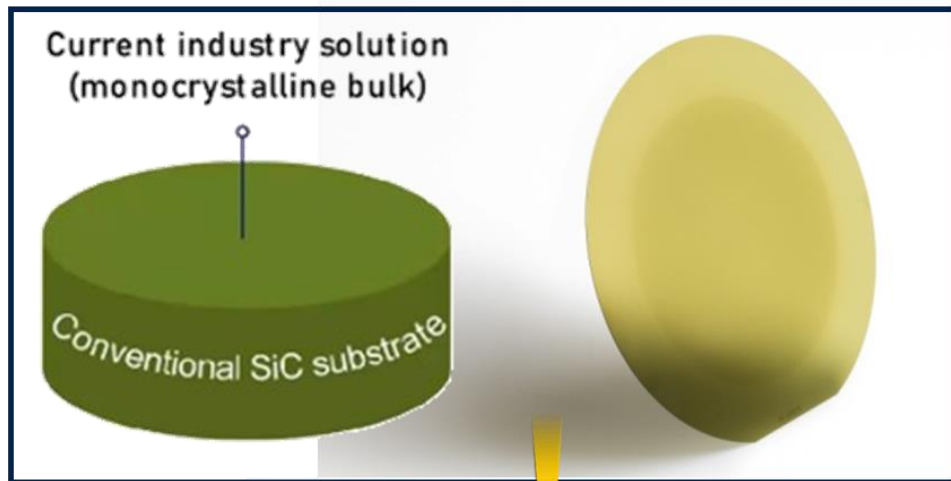
- Fine-tuning of testing in EWS and back-end
- Burn in testing for new technologies
- DOLI implementation for known defects

Mission profile assessment



- Analysis of customer specific mission profile
- Fine-tuning of testing and reliability assessment
- Equivalent FIT evaluation

Looking to use SOITEC SmartSiC to advance manufacturing

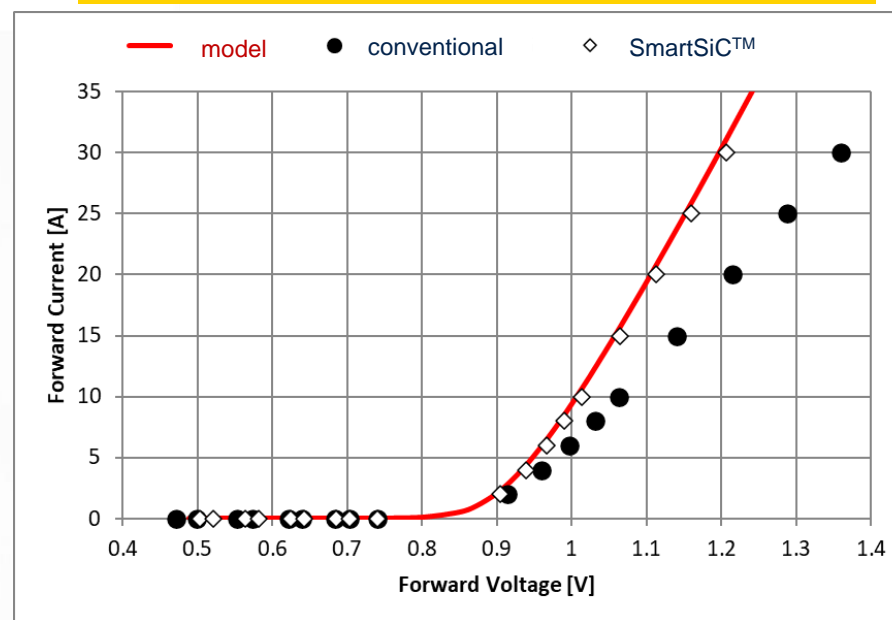


courtesy of SOITEC

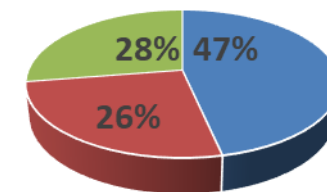
Value proposition

- High increase of number of producible wafers
- Maximize substrate value
- Device feature size reduction / RDSon improvement
- Copy & paste of MOSFET process flow
- Acceleration of the path to 200mm transition

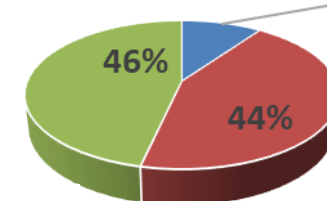
Experimental data on 650V SiC diode



■ Rsub ■ Rc ■ Rdrift



■ Rsub ■ Rc ■ Rdrift



$$\Delta R @ RT = 33m\Omega \cdot mm^2$$

Vertically integrating for supply chain robustness

Raw material → SiC ingots & substrates → SiC dice manufacturing → discrete/module design & manufacture → Finished products

Norrköping SiC substrate R&D plant



- 150 mm production
- 200 mm with industrial quality and yields

Catania new integrated SiC plant

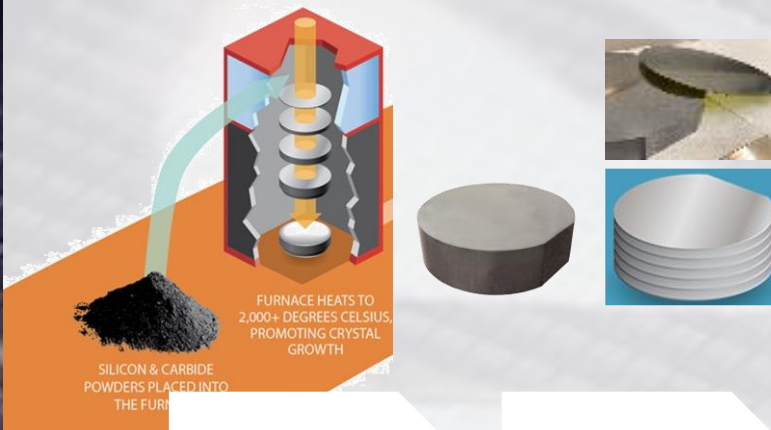


- Pilot production started in 2023*
- 150 mm substrates + epitaxy (converting to 200 mm)

* targeting > 40% substrate in-sourcing by 2024

Vertical integration, from powder to final product

Substrate technology



SiC ingot

Wafer Slicing & polishing

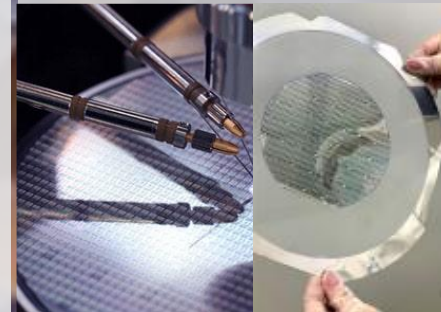
Front-end technology



Epitaxy

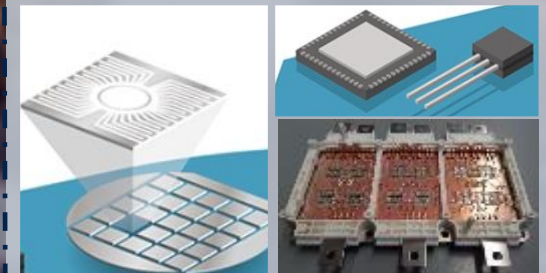
Device fabrication
lithography,
deposition, etching,
thermal treatment
metallization, etc.

Testing



Wafer testing
(Electrical
Wafer sorting)
& wafer level
burning

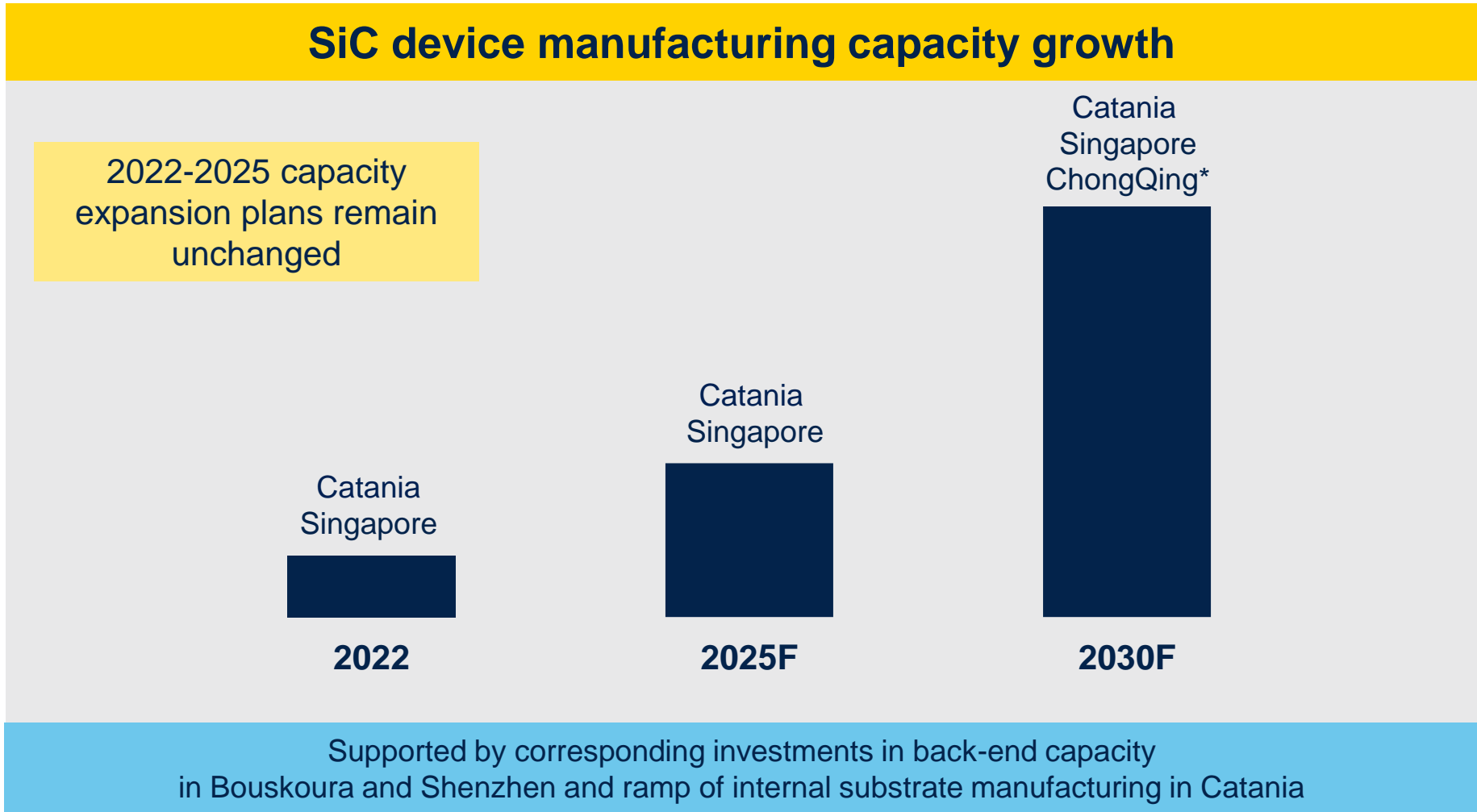
Back-end technology (assembly)



Dicing
(singulation)

Packaging

Expansion of silicon carbide manufacturing capacity



* Dedicated JV with Sanan in China to address the local market

Takeaways

Silicon carbide is key in **power conversion efficiency**

Demand for SiC is growing quickly due to its extensive use in electric vehicle subsystems.

Investment in a **vertically integrated** approach essential to improve output and address market needs

Continued development of the technology node to improve power density

ST SiC MOSFET technology is **state-of-the-art and best positioned** to support the growth today

Our technology starts with You



Find out more at www.st.com

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